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78

U.S. UTILITY Patent Application



PATENT NUMBER and
ISSUE DATE

APPL NUM 10005347	FILING DATE 12/07/2001	CLASS 524	SUBCLASS	GAU 1712	EXAMINER
**APPLICANTS: Kozawa Miwa; Watanabe Keiji; Yano Ei;					
**CONTINUING DATA VERIFIED: <i>yes</i> THIS APPLICATION IS A DIV OF 09/553,479 04/20/2000 PAT 6,342,562 <i>Keiji</i>					
** FOREIGN APPLICATIONS VERIFIED: <i>yes</i> JAPAN 11-116517 04/23/1999 JAPAN 2000-000000 03/23/2000 <i>Keiji</i>					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no		35 USC 119 conditions met <input checked="" type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO 100021-00065	
Verified and Acknowledged Examiners's initials <i>KLJ</i> TITLE : Silicon-containing polymer, process for its production, resist composition employing it, pattern-forming method and electronic device fabrication method <small>U.S. DEPT. OF COMM. / PAT. & TM. PTO-436L (Rev. 12-24)</small>					

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims <i>5</i>	Print Claim for O.G. <i>1, 3</i>
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg. <i>1</i>	Figs. Drwg. <i>3</i>
		Print Fig. <i>—</i>	
<input type="checkbox"/> TERMINAL DISCLAIMER		Primary Examiner PREPARED FOR ISSUE Application Examiner	
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